



ADVANCE PROGRAM

2023 DISPLAY WEEK INTERNATIONAL SYMPOSIUM

May 23-26, 2023 (Tuesday – Friday)
Los Angeles Convention Center
Los Angeles, California, US

Session 1: Annual SID Business Meeting

Tuesday, May 23, 2023 / 8:00 – 8:20 am / Hall G

Session 2: Opening Remarks / Keynote Addresses

Tuesday, May 23, 2023 / 8:20 – 10:20 am / Hall G

Chair: *Wei Yao, Apple, Inc.*

- 2.1: **Keynote Address 1: New Trends and Strategies for the Display Industry**
Charles Peng, Chairman and Chief Executive Officer, Tianma Microelectronics Co., Ltd.
- 2.2: **Keynote Address 2: Advanced Optics for Immersive AR**
Kevin Curtis, Senior VP, Head of Hardware, Magic Leap
- 2.3: **Keynote Address 3: Forecasting the Future of the Display Industry Post COVID**
Ross Young, Co-Founder and CEO, DSCC

Session 3: Emerging Technologies and Techniques I (Emerging Technologies and Applications)

Tuesday, May 23, 2023 / 11:10 AM - 12:30 PM / Room 402AB

Chair: *Susan Jones, Nulumina Corp.*

Co-Chair: *John-Ho Hong, Samsung*

- 3.1: **Distinguished Paper: High-Resolution Active-Matrix MicroLED Stretchable Displays**
Haeyoon Jung, LG Display, Seoul, South Korea
- 3.2: **Integration of Dye-Sensitized Solar Cell and Liquid-Crystal Display Technologies**
Yuki Kyoda, Sharp Corporation, Tenri, Japan
- 3.3: **Large-FoV Fast LiDAR System Based on Electrically Suppressed Helix Ferroelectric Liquid Crystal**
Yuechu Cheng, The Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 3.4: **Invited Paper: A 2.5 μ m Dot-Pitch 0.18-in. OLED Microdisplay on 28nm CMOS Backplane**
Philipp Wartenberg, Fraunhofer Institute for Organic Electronics, Dresden, Germany
- 3.5: **Privacy Device Using Peripheral Encoding**
Timothy Large, Microsoft (UK) Ltd, Reading, United Kingdom

Session 4: MicroLED for AR/VR/MR I (AR/VR/MR / Emissive, Micro-LED, and Quantum-Dot Displays)

Tuesday, May 23, 2023 / 11:10 AM - 12:30 PM / Room 408A

Chair: *Jisoo Hong, Korea Electronics Technology Institute*

Co-Chair: *Jean-Jacques Drolet, Osram Opto Semiconductors*

- 4.1: **Invited Paper: Industrializing MicroLED Microdisplays for AR Applications**
Wei Sin Tan, Jade Bird Display Limited, Shanghai, China
- 4.2: **Invited Paper: Unlocking MicroLED Display Solutions for Consumer AR Glasses**
Tongtong Zhu, Porotech, Cambridge, United Kingdom
- 4.3: **MicroLED Display on 300mm CMOS Platform: Crosstalk and Optical Outcoupling**
Soeren Steudel, MICLEDI microdisplay BV, Leuven, Belgium
- 4.4: **High-ppi MicroLED Display Driver Circuit and Device Structure**
Jiao Zhao, BOE Technology Group Co., Ltd., Beijing, China

Session 5: Liquid Crystal AR/VR/MR Applications I (AR/VR/MR / Liquid Crystal Technology)

Tuesday, May 23, 2023 / 11:10 AM - 12:50 PM / Room 408B

Chair: *Matthew Sousa, 3M*

Co-Chair: *Philip Chen, National Yang Ming Chiao Tung University*

- 5.1: **Invited Paper: Infinite Display for Meta Quest Pro**
Linghui Rao, Meta, Redmond, WA US
- 5.2: **Invited Paper: High-Dynamic-Range 2,117ppi LCD for VR Displays**
Yung-Hsun Wu, Innolux Corporation, Miaoli, Taiwan Roc
- 5.3: **Invited Paper: Development of Fast LCD with MiniLED BLU for VR Application**
Hao Zhang, BOE Technology Group Co., LTD., Beijing, China
- 5.4: **Invited Paper: High-Performance LCD for Future VR**
Fenglin Peng, Meta, Redmond, WA US
- 5.5: **Development of 1500-ppi VR LCD Based on LTPO Process Structure**
Zhen. Zhang, BOE Technology Group Co., Ltd., Beijing, China

Session 6: ML-Based Defect Detection Techniques (Machine Learning for Displays / Display Manufacturing)

Tuesday, May 23, 2023 / 11:10 AM - 12:10 PM / Room 406

Chair: Chaohao Wang, YLab

Co-Chair: Ion Bitu, Google LLC

6.1: **MOVED TO P.175**

6.2: **Potential Failure Detection Using Unsupervised Clustering and Anomaly Detection**
Seokhyun Yoon, Samsung Display, Asan, South Korea

6.3: **Identifying the Cause of Pixel Defects via a Machine Learning Method**
Jun Hee Han, LG Display, Seoul, South Korea

6.4: **Deep Learning for Classification of Repairable Defects in Display Panels Using Multi-Modal Data**
Qisen Cheng, Samsung Display America Lab, San Jose, CA US

Session 7: Driving Circuit for Advanced Displays (Display Electronics)

Tuesday, May 23, 2023 / 11:10 AM - 12:30 PM / Room 404

Chair: Dr. Bong-Hyun You, Samsung Display Co.

Co-Chair: Dr. Juhn Yoo, LG Display

7.1: **New a-IGZO TFT Pixel Circuit for High-Resolution Mobile AMOLED Display for Good Optical Uniformity at Low Gray Levels**
Jihwan Park, Seoul National University, Seoul, South Korea

7.2: **A Low-Power Pixel Circuit Using Extra Current Source for MiniLED Displays**
Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan

7.3: **A New Line-by-Line SWEEP Signal-Generation Method for PWM Driving MicroLED TFT Pixel Circuit**
Kyeongsoo Kang, Seoul National University, Seoul, South Korea

7.4: **Novel a-IGZO TFT MicroLED Circuit with Improved Stability and Area Efficiency**
Chanjin Park, Seoul National University, Seoul, South Korea

Session 8: High Mobility TFTs (Active Matrix Devices)

Tuesday, May 23, 2023 / 11:10 AM - 12:30 PM / Room 403A

Chair: Yusin Lin, Applied Materials, Inc.

Co-Chair: Ivan Wu, AU Optronics Corp

8.1: **Invited Paper: High Mobility Poly-Crystalline Oxide TFT Achieves Mobility over 50 cm²/Vs and High Level of Uniformity in Large Substrates**
Masashi Tsubuku, Japan Display Inc., Chiba, Japan

8.2: **Invited Paper: High-Mobility Top-Gate Self-Alignment Oxide TFT Technology for 14.5-in. 3K x 2K Narrow-Bezel Notebook LCD**
Shao Xianjie, Nanjing BOE Display Technology Corporation, Nanjing, China

8.3: **Invited Paper: High Mobility and Photo-Stable Amorphous Oxide Thin-Film Transistors**
Junbiao Peng, South China University of Technology, Guangzhou, China

8.4: **Oxide Semiconductor In-Zn-O-X System with High Electron Mobility**
Shigeki Tokuchi, Mitsui Mining & Smelting Company, Ltd., Ageo, Japan

Session 9: OLED Devices (OLEDs)

Tuesday, May 23, 2023 / 11:10 AM - 12:30 AM / Room 403B

Chair: CC Lee, Visionox

Co-Chair: Changwoong Chu, Samsung Display Company

9.1: **Invited Paper: Triplet-Triplet Annihilation at Organic Semiconductor Interface for Efficient Solid-State Photon Upconversion and Organic Light-Emitting Diodes with Low Driving Voltage**

Seiichiro Izawa, Tokyo Institute of Technology, Tokyo, Japan

9.2: **TurboLED: Novel Pixel Design for Reduced Power Consumption and Expanded Color Gamut**
Peter Levermore, Exciton Limited, Sedgefield, United Kingdom

9.3: **NIR OLEDs Using NIR Emitters and Optical Effects for Wavelength Control in NIR Light Region**
Kyung Cheol Choi, Korea Advanced Institute of Science and Technology (KAIST), Daejeon, South Korea

9.4: **Late-News Paper: Full-Color Organic Light-Emitting Diodes on Silicon Microdisplay with Ultra-High Luminescence and High Resolution**
Tengfei Liu, Nanjing Guozhao Optoelectronics Technology Co., LTD., Nanjing, China

Session 10: Resolution and MTF Measurements (Display Measurement)

Tuesday, May 23, 2023 / 11:10 AM - 12:30 PM / Room 411

Chair: Stephen Atwood, Consultant

Co-Chair: Thomas Fiske, Consultant

10.1: **Resolution Evaluation Using MTF for a High-Definition Floating Display**
Kazuki Shimose, Kyocera Corporation, Yasu, Japan

10.2: **Line-Based Modulation Transfer Function Measurement of Aerial Display by Use of Arrayed Optical Elements**
Kazuaki Takiyama, Utsunomiya University, Utsunomiya, Japan

10.3: **Resolution Capability Measurements: A Comparison Between MTF Slanted Line and Pixel Crosstalk**
Ingo Rotscholl, TechnoTeam Bildverarbeitung GmbH, Ilmenau, Germany

10.4: **Method for Separating the Optical and Display Contributions to Spatial Resolution in Augmented-Reality Displays**
Ryan Beams, Food and Drug Administration, Silver Spring, MD US

Session 11: Emerging Technologies and Techniques II (Emerging Technologies and Applications)

Tuesday, May 23, 2023 / 2:00 PM - 3:40 PM / Room 402AB

Chair: Vincent Gu, Apple, Inc.

Co-Chair: Jim Zhuang, Meta

11.1: **AI-Based Interaction Commonality Analysis**

Seokhyun Yoon, Samsung Display, Asan, South Korea

11.2: **A 9kfps 1,411ppi GaN-Based μ LED Display CMOS Backplane**
Victor Moro, Universitat de Barcelona, Barcelona, Spain

- 11.3: **A Novel e-Privacy LCD Based on a Smart Viewing-Angle Controllable Cell with IPS Electrode Structure**
Yijun Wang, Hefei BOE Optoelectronics Technology Co., Ltd., Hefei, China
- 11.4: **3.55-Watt Output Power LTPS-TFT DCDC Converter for Actuators on Flexible Substrate Wearable Devices**
Nikolaos Papadopoulos, imec, Heverlee, Belgium
- 11.5: **Invited Paper: Evolving into an Era of Natively Flexible Smart Systems**
Feras Alkhalil, Pragmatic Semiconductor Limited, Sedgefield, United Kingdom

Session 12: MicroLED for AR/VR/MR II (AR/VR/MR / Emissive, Micro-LED, and Quantum-Dot Displays)

Tuesday, May 23, 2023 / 2:00 PM - 3:20 PM / Room 408A

Chair: *Jinsoo Jeong, KETI*

Co-Chair: *Chris Bower, X Display Company*

- 12.1: **Invited Paper: Recent Progress on Active-Matrix Addressable MicroLEDs for High-Performance Displays**
Ke Zhang, Shenzhen Sitan Technology Co., Ltd., Shenzhen, China
- 12.2: **Distinguished Paper: High-Efficiency Nanowire LEDs for AR/VR Displays**
Yizhou Qian, University of Central Florida, Orlando, FL US
- 12.3: **Invited Paper: Nanowire MicroLEDs for Augmented-Reality and Virtual-Reality (AR/VR) Displays**
Seth Coe-Sullivan, NS Nanotech, Inc., Ann Arbor, MI US
- 12.4: **Invited Paper: Enhancing microLED Manufacturing with New Horizons in Metrology and High-Throughput EL Inspection**
David Lewis, InZiv, Jerusalem, Israel

Session 13: Liquid Crystal AR/VR/MR Applications II (AR/VR/MR / Liquid Crystal Technology)

Tuesday, May 23, 2023 / 2:00 PM - 3:20 PM / Room 408B

Chair: *Linghui Rao, Meta*

Co-Chair: *Yung-Hsun Wu, Innolux*

- 13.1: **Invited Paper: Front-Lit LCOS for AR Displays**
Yuet-Wing Li, Himax Display Inc., Tainan, Taiwan Roc
- 13.2: **Invited Paper: Advanced Patterning Method Exceeding the Lithography Limitation with Resolution Enhancement Technology**
Yoshisuke Toyama, Merck Electronics Ltd., Shizuoka, Japan
- 13.3: **Full-Color Optical Combiner with Good Imaging Quality and a Wide Angle of Incident Light Acceptance**
Fenglin Xi, Kent State University, Kent, OH US

Session 14: ML-Based Design and Modeling Techniques (Machine Learning for Displays / Display Manufacturing / Emerging Technologies and Applications / Display Electronics)

Tuesday, May 23, 2023 / 2:00 PM - 3:20 PM / Room 406

Chair: *Suk-Ju Kang, Sogang University*

Co-Chair: *Fang-Cheng Lin, Apple, Inc.*

- 14.1: **An Automatic Panel Design Using AI-Based Design Optimization and Standard Design**
Ju-Un Park, LG Display, Seoul, South Korea
- 14.2: **Angle-Insensitive Meta-Surface Color Filters Designed by Integrating Genetic Algorithm with Artificial Neural Network**
Yun Seon Do, Kyungpook National University, Daegu, South Korea
- 14.3: **Drop Resistance Optimization Through Post-Hoc Analysis of Chemically Strengthened Glass**
Myunghun Baek, Samsung Display Co., Ltd., Yongin, South Korea
- 14.4: **Efficient Multi-Stage Bayesian Optimization for Optimal Display Circuit Input Signal Design**
Shuhui Qu, Samsung Semiconductor, Inc., San Jose, CA US

Session 15: Image Quality Improvement Technology (Display Electronics)

Tuesday, May 23, 2023 / 2:00 PM - 3:20 PM / Room 404

Chair: *Carlin Vieri, Google*

Co-Chair: *Feng-Ting Pai, Novatek Microelectronics Corp.*

- 15.1: **New Compression Algorithm to De-Mura Gamma LUT for AMOLED Display**
Yini Zuo, Chengdu BOE Optoelectronics Group Co., Ltd., Chengdu, China
- 15.2: **A Novel Compensation Algorithm for Multi-Frame Drop on AMOLED Displays**
Shang-Yu Su, Novatek Microelectronics Corporation, Hsinchu, Taiwan Roc
- 15.3: **Crosstalk Compensation Method Using ELVDD Coupling Modeling in OLED Display for Mobile Application**
Tae-Kon Yu, Samsung Electronics Co. Ltd., Hwaseong, South Korea
- 15.4: **Improvement of Gradation and Color Shift in Dark Luminance Area with Signal Correction for OLED Displays**
Masafumi Ueno, Sharp Display Technology Corporation, Nara, Japan

Session 16: Integrated Sensors (Active Matrix Devices)

Tuesday, May 23, 2023 / 2:00 PM - 3:20 PM / Room 403A

Chair: *James Chang, Apple, Inc.*

Co-Chair: *Mike Hack, Universal Display Corporation*

- 16.1: **Invited Paper: High-Performance Organic/Polymeric Field-Effect Transistors for Intrinsic Flexible Display**
Yunqi Liu, Chinese Academy of Sciences, Beijing, China
- 16.2: **Invited Paper: Ambient Light Sensor Integration in a-Si LCD with Regular Processing**
Dou Shuqian, BOE, Beijing, China
- 16.3: **Invited Paper: Solution-Processed Metal-Oxide Thin-Film Transistors for Flexible Active-Matrix Sensor Arrays**
Bowen Zhu, Westlake University, Hangzhou, China

Session 17: OLED Displays I (OLEDs)

Tuesday, May 23, 2023 / 2:00 PM - 3:40 PM / Room 403B

Chair: *Yifan Zhang, Apple, Inc.*

Co-Chair: *Sangmoo Choi, Google LLC*

- 17.1: **Invited Paper:** Development of Novel eLEAP AMOLED Display with Breakthrough Panel Performance
Naoki Shiomi, Japan Display Inc., Chiba, Japan
- 17.2: Development of Visionox Intelligent Pixelization Technology in AMOLED Applications
Yiming Xiao, Hefei Visionox Technology Ltd., Hefei, Anhui, China
- 17.3: An 8.3-in. 1,058ppi OLED Display with Side-by-Side Pixel Structure Fully Fabricated by Photolithography
Shingo Eguchi, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan
- 17.4: Ultra-High-Resolution Full-Color OLEDs Patterned by Photolithography
Ryungyu Lee, Soongsil University, Seoul, South Korea
- 17.5: Enhancement of Luminance Efficiency of 3,000ppi OLED Microdisplay Using RGB Direct Patterning
Jae Hoon Jung, APS Research Corporation, Hwasung, South Korea

Session 18: Topics in Display Measurement (Display Measurement)

Tuesday, May 23, 2023 / 2:00 PM - 3:20 PM / Room 411

Chair: *Thomas Fiske, Consultant*

Co-Chair: *Jaejoong Kwon, Samsung Display*

- 18.1: Combining Annulus and Variable Aperture Source Methods to Separate Specular, Haze, and Lambertian Reflection Components in e-Paper Displays
Dirk Hertel, E Ink Corporation, Billerica, MA US
- 18.2: Equivalent Conditions for Display Sparkle Contrast Measurement with Different Optical Magnification
Masanobu Isshiki, AGC Inc., Tokyo, Japan
- 18.3: Computing Display Color Gamut Volume Using Tetrahedra
Charles Poynton, Consultant, Toronto, ON Canada
- 18.4: **Late-News Paper:** Lambda Capture Method and Applications for Quality Control of Displays and Devices
Tomonori Nakamura, Hamamatsu Photonics K.K., Hamamatsu, Japan

Session 19: Holographic and 3D Optics (Emerging Technologies and Applications)

Tuesday, May 23, 2023 / 3:40 PM - 5:00 PM / Room 402AB

Chair: *Maple Peng, Meta*

Co-Chair: *Adi Abileah, Adi - Displays Consulting LLC*

- 19.1: **Distinguished Paper:** Mirror-Transcending Aerial Imaging: An Optical System that Freely Crosses the Boundary Between Mirrored and Real Spaces
Ayaka Sano, NTT Human Informatics Laboratories, Yokosuka, Japan
- 19.2: A Novel 3D Floating Image for Human-Machine Interfaces
Yi-Hsiang Huang, Industrial Technology Research Institute, Hsinchu, Taiwan Roc
- 19.3: Slim Backlights for Holographic 3D Displays Through Advanced Coatings
Ullrich Hartung, Fraunhofer FEP, Dresden, Germany
- 19.4: Improving Defocus Blur in Holographic Displays
Janos Keresztes, University College London, London, United Kingdom

Session 20: AR/VR/MR Visual Experience (AR/VR/MR / Applied Vision)

Tuesday, May 23, 2023 / 3:40 PM - 5:20 PM / Room 408A

Chair: *David Hoffman, Google*

Co-Chair: *Scott Murdison, Facebook Reality Labs*

- 20.1: **Invited Paper:** Rethinking Display Requirements for e-Sports and High Interactivity Applications
JooHwan Kim, NVIDIA Corporation, Santa Clara, CA US
- 20.2: **Distinguished Paper:** Local Pupil Swim in VR/AR: Root Cause and Perception Model
Jerry Jia, Meta Reality Labs, Menlo Park, CA US
- 20.3: The Study of Ambient Contrast Ratio of Transparent MicroLED Displays for Applied Field Extension
Chien-Huang Liaw, AUO Corporation, Hsinchu, Taiwan Roc
- 20.4: An AI-Driven Aquarium Guide System for Museum
Te-Chih Liu, Industrial Technology Research Institute, Zhudong Township, Hsinchu County, Taiwan Roc
- 20.5: Novel Interactive Mixed-Reality System Based on Dual-Depth Camera Gesture Recognition for Human-Computer Interaction
Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan Roc

Session 21: MicroLED Color Conversion (Emissive, Micro-LED, and Quantum-Dot Displays)

Tuesday, May 23, 2023 / 3:40 PM - 5:20 PM / Room 408B

Chair: *Michele Ricks, EMD Electronics*

Co-Chair: *Jonathan Steckel, ST Microelectronics*

- 21.1: **Invited Paper:** Technology Trends and Challenges for Large MicroLED Display Applications
Chen-Ke Hsu, Sanan Optoelectronics Co., LTD, Xiamen, China
- 21.2: Full-Color Micro-LED Displays Based on Quantum Dots
Yanzhen Yin, Southern University of Science and Technology, Shenzhen, China
- 21.3: Quantum-Rod Color Filter with Higher Display Ambient Contrast Ratio
Yiyang Gao, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 21.4: Elevating the Light Output Power Density of Scaling-Down AlGaIn Ultraviolet-C MicroLEDs
Feng Feng, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 21.5: Far-Field Native Emission Patterns of Various MicroLED Structures
Khaled Ahmed, Intel Corporation, Santa Clara, CA US

Session 22: ML-Based High Quality Image Techniques (Machine Learning for Displays / Display Electronics / Display Measurement)

Tuesday, May 23, 2023 / 3:40 PM - 5:00 PM / Room 406

Chair: Prof. Hyoungsik Nam, Kyung Hee University

Co-Chair: Prof. Soo-Yeon Lee, Seoul National University

- 22.1: **Novel Gamma Prediction Algorithm for FDC Region of AMOLED Panel Based on CNN Model**
Chaofan Xu, Chengdu BOE Optoelectronics Group Co., Ltd., Chengdu, China
- 22.2: **Low-Power-Consumption Optimization Using Conformalized Quantile Regression**
Kyongtae Park, Samsung Display Co., Ltd., Yongin, South Korea
- 22.3: **An Adaptive Frequency Domain De-Moiré Method for Display Test Images**
Gang Xu, Jince Electronics, USA, San Jose, CA US
- 22.4: **Invited Paper: Deep Learning-Based Image Deblurring for Display Vision Inspection**
Suk-Ju Kang, Sogang University, Seoul, South Korea

Session 23: Thermal Modeling and High Speed Interface (Display Electronics)

Tuesday, May 23, 2023 / 3:40 PM - 4:40 PM / Room 404

Chair: Darren Kim, Google LLC

Co-Chair: Moon-Sang Hwang, Samsung Display Co., Ltd.

- 23.1: **OLED Panel Power Consumption and Heat-Generation Modeling According to Driving Environment**
Daegwang Jang, Samsung Display, Yongin, South Korea
- 23.2: **Operation Method of Dynamic Data Rate for High-Speed Signal Transmission on Display System**
Chien-Hao Li, Novatek Microelectronics Corporation, Hsinchu, Taiwan Roc
- 23.3: **Distinguished Paper: A Clock Embedded Intra-Panel Interface with 1.96% Data Overhead for Beyond 8K Displays**
Yong-Yun Park, Samsung Electronics Co. Ltd., Hwasung, South Korea

Session 24: Novel Driving Circuits (Active Matrix Devices)

Tuesday, May 23, 2023 / 3:40 PM - 5:00 PM / Room 403A

Chair: Jae-Hoon Lee, Samsung Display Co

Co-Chair: Takahashi Nakamura, Japan Display Inc.

- 24.1: **Invited Paper: A Novel Algorithm for Eliminating Abnormal Detection Data in Ultra-Large 95-in. 8K OLED Panels with External Compensation**
Xuehuan Feng, Hefei BOE Joint Technology Co., Ltd., Hefei, China
- 24.2: **Facile Design of Gate Driver Integrated Circuit with Self-Aligned InGaZnO TFTs Using Multi-Outputs and Common Bootstrapped Driving for High-Resolution WOLED Displays**
Hyun Jae Kim, Yonsei University, Seoul, South Korea
- 24.3: **Invited Paper: PAM and PWM Driving Comparison for MicroLED Display**
Yangen Wu, AUO Corporation, Hsinchu, Taiwan Roc
- 24.4: **Invited Paper: Flickering in Low-Frame-Rate Driven AMOLEDs**
Kook Chul Moon, Gachon University, Seongnam, South Korea

Session 25: OLED Displays II (OLEDs)

Tuesday, May 23, 2023 / 3:40 PM - 5:00 PM / Room 403B

Chair: DZ Peng, Tianma

Co-Chair: Ji Ho Baek, LG Display

- 25.1: **Distinguished Paper: Novel Ultra-Large OLED Display for Premium TVs**
Hong Jae Shin, LG Display, Paju, South Korea
- 25.2: **Subpixel Optimization in AMOLED Displays by Self-Assembled Patterning of a Secondary Cathode**
Zhibin Wang, OTI Lumionics Inc., Mississauga, ON Canada
- 25.3: **Design and Fabrication of Under-Display Camera OLED Panel**
Ming Yang, BOE Technology Group Co., Ltd., Beijing, China
- 25.4: **High-Resolution Top-Emission OLED Device Fabricated by Inkjet Printing Process**
Huifeng Wang, Hefei BOE Joint Technology Co., Ltd., Hefei, China

Session 26: Automotive Display Measurements (Automotive/Vehicular Displays and HMI Technologies / Display Measurement)

Tuesday, May 23, 2023 / 3:40 PM - 5:00 PM / Room 411

Chair: Karlheinz Blankenbach, Pforzheim University

Co-Chair: Stephen Atwood, Consultant

- 26.1: **Invited Paper: Overall Performance Measurement of Automotive Autostereoscopic Displays**
Achim Pross, Mercedes-Benz AG, Sindelfingen, Germany
- 26.2: **Quantitative Evaluation of Display Readability in a Car Simulator Under Ambient Light Conditions**
Michael Linder, Corning GmbH, Wiesbaden, Germany
- 26.3: **Assessing Vehicle Driver Performance in Dual-Depth Head-Up Displays**
Tzu An Chou, National Taiwan University Of Science And Technology, Taipei, Taiwan Roc
- 26.4: **Late-News Paper: Preferred White Point for a System of Mixed Technology Displays Cockpit**
Pooshpanjan Roy Biswas, Renault, Guyancourt, France

Session 27: Emerging Integrated Sensors (Emerging Technologies and Applications)

Wednesday, May 24, 2023 / 9:00 AM - 10:20 AM / Room 402AB

Chair: Adi Abileah, Adi - Displays Consulting LLC

Co-Chair: Abhishek Srivastava, Hong Kong University of Science & Technology

- 27.1: **A Low-Noise 17 x 17-in. IGZO X-Ray Sensor Panel**
Ray Chen, AU Optonics Corporation, Hsinchu, Taiwan Roc
- 27.2: **Field Emission Beyond Information Displays**
Salvador Barranco Cárceles, University of Edinburgh, Edinburgh, United Kingdom
- 27.3: **Deformed Helix Ferroelectric Liquid-Crystal Based Threshold-Less Passive Vibration Sensing System**

- Abhishek Srivastava, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
27.4: **Development of a Novel Glass-Cell FAIMS Olfactory Sensor and Measurements of Complex Odors**
Reshan Abeysinghe, Sharp Display Technology Corporation, Nara, Japan

Session 28: AR/VR/MR Optical Systems (AR/VR/MR / Display Systems)

Wednesday, May 24, 2023 / 9:00 AM - 10:40 AM / Room 408A

Chair: *W. Hendrick, Collins Aerospace*

Co-Chair: *Jean-Pierre Guillou, Apple, Inc.*

- 28.1: **Foveated Imaging for AR Displays Based on Polarization Selective Flat Lenses**
Qian Yang, University of Central Florida, Orlando, FL US
- 28.2: **Eyebox-Expanded Maxwellian-View Augmented-Reality Display with a Color Holographic Optical Element**
Xinxing Xia, Shanghai University, Shanghai, China
- 28.3: ***Distinguished Paper:* Optimizing Microdisplay Requirements for Pancake VR Applications**
En-Lin Hsiang, University of Central Florida, Orlando, FL US
- 28.4: **1.50-in. 3,207ppi OLED Display and Optical System for VR Use**
Hisao Ikeda, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan
- 28.5: **Anamorphic DLP Illumination System Design with a Freeform Surface Lens**
Jui-Wen Pan, National Yang Ming Chiao Tung University, Tainan, Taiwan Roc

Session 29: MicroLED Device & Efficiency (Emissive, Micro-LED, and Quantum-Dot Displays)

Wednesday, May 24, 2023 / 9:00 AM - 10:40 AM / Room 408B

Chair: *Prof. Zhaojun Liu, Southern University of Science and Technology*

Co-Chair: *Ioannis Kymissis, Columbia University*

- 29.1: ***Invited Paper:* Emitters for Flat-Panel MicroLED Displays**
Matthew Meitl, X Display Company, Inc., Research Triangle Park, NC US
- 29.2: ***Invited Paper:* Temporal Study of MicroLED Arrays for Potential High-Efficiency Driving**
Qun (Frank) Yan, Fuzhou University, Fuzhou, China
- 29.3: **Exploring the Temperature Dependence of GaN-on-GaN Homoepitaxy MicroLEDs**
Zichun Li, Hong Kong University of Science and Technology, Clear Water Bay, Kowloon, Hong Kong
- 29.4: **Higher External Quantum Efficiency with Lower Current Density Injection of <10µm Pixel Size Arrays for Display Application**
Yibo Liu, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 29.5: ***Invited Paper:* Progress in MicroLEDs: Materials, Device Performance, and Reliability**
Brendan Moran, Lumileds LLC, San Jose, CA US

Session 30: LED Displays (Outdoor Displays / Display Systems / Emissive, Micro-LED, and Quantum-Dot Displays)

Wednesday, May 24, 2023 / 9:00 AM - 10:30 AM / Room 406

Chair: *Karlheinz Blankenbach, Pforzheim University*

Co-Chair: *Samantha Phenix, Phenix Consulting*

- 30.1: ***Invited Paper:* High-Resolution Outdoor dvLED Displays and Their Potential to Replace Outdoor LCDs**
James Wickenhiser, SiliconCore Technology, Inc., Milpitas, CA US
- 30.2: ***Late-News Paper:* LED Outdoor Display - The New Advertising Column - Challenges and Requirements**
Gunmar Grieser, Stroer Media Deutschland GmbH, Koeln, Germany
- 30.3: **Open Standard Software Defines AV over IP Framework for LED Video Wall System**
Benjamin Cope, Intel Corporation, Marlow, UNK United Kingdom
- 30.4: ***Distinguished Paper:* Design of Outdoor LED Ground Display System in Major Scenes**
Yu Chao, BOE Technology Group, Beijing, China
- 30.5: ***Late-News Paper:* Development of a highly reliable Mini-LED display module using simultaneous transfer and bonding (SITRAB) technology**
Jiho Joo, Electronics and Telecommunications Research Institute, Daejeon, South Korea

Session 31: Capacitive Force, Touch, and Stylus Sensing (Interactive Displays and Systems)

Wednesday, May 24, 2023 / 9:00 AM - 10:20 AM / Room 404

Chair: *Patrick Worfolk, AMD*

Co-Chair: *Deuk-Su Lee, LG Display*

- 31.1: **Active Stylus Application Using Self-Capacitive Touch with OLED TDDI**
Yu-Ying Tang, Novatek Microelectronics Corp., Hsinchu, Taiwan Roc
- 31.2: **An Asynchronous Single-Ended Touch-Sensing Method for Y-OCTA Using Adaptive TX Duty Control Method**
Jin-Chul Lee, Samsung Electronics, Hwaseong, South Korea
- 31.3: **In-Cell Touch-Supported Novel Reflective LCD Mode Development**
Shinichi Terashita, Sharp Display Technology Corporation, Nara, Japan
- 31.4: **Sharp Force Touch for On-Screen User Interface in LCD and Foldable OLED Display Application**
Takuma Yamamoto, Sharp Display Technology Corporation, Nara, Japan

Session 32: Novel Processes (Active Matrix Devices)

Wednesday, May 24, 2023 / 9:00 AM - 10:20 AM / Room 403A

Chair: *Junho Song, Korea University*

Co-Chair: *Sang Hee Park, KAIST*

- 32.1: ***Invited Paper:* Mask-Reduction Process with Innovative Undercut for Large AMOLED Display**
Jiayang Fei, Shenzhen China Star Optoelectronics Semiconductor Display Technology Co. Ltd., China, Shenzhen, China
- 32.2: **Mask-Reducing Backplane Architecture for Advanced MicroLED Display**
Kai Zhou, Shenzhen China Star Optoelectronics Semiconductor Display Technology Co. Ltd., Shenzhen, China
- 32.3: ***Late-News Paper:* Development of 540Hz LCD with Low-Resistance Gate LTPS Technology**
Jia-Hong Ye, AUO Corporation, Hsinchu, Taiwan Roc

32.4: **Late-News Paper: A 1.03-in. 2,560 x 2,560 3,514ppi Low-Power OLEDs Backplane with In-Pixel Up-Scaling Technique**
Dongssoon Jung, Raontech Inc., Seongnam, South Korea

Session 33: OLED Materials I (OLEDs)

Wednesday, May 24, 2023 / 9:00 AM - 10:20 AM / Room 403B

Chair: Hitoshi Kuma, Idemitsu Kosan Co., Ltd.

Co-Chair: Larry Liao, Soochow University

- 33.1: **Invited Paper: Development of Deuteration Technology to Improve Lifetime of OLED EX and Identification of Stability of Deuterated Materials**
Young-Jun YU, LG Display, Seoul, South Korea
- 33.2: **Invited Paper: Multiple-Resonance Boron-Nitrogen Materials: Effective Emitters for High-Performance Green-Emission OLEDs**
Xudong Cao, Jiangsu Sunera Technology Co., Ltd., Wuxi, China
- 33.3: **Invited Paper: Shaping the Emissive Layer of Green Phosphorescent OLEDs: High-Performance Hosts for Various Dopants and Applications**
Sebastian Stolz, Merck Electronics KGaA, Darmstadt, Germany
- 33.4: **Supramolecules in Thin Films and OLED Efficiencies**
Hadi Abroshan, Schrödinger, Inc., Portland, OR US

Session 34: Automotive HUDs and Driver Monitoring (Automotive/Vehicular Displays and HMI Technologies)

Wednesday, May 24, 2023 / 9:00 AM - 10:20 AM / Room 411

Chair: Haruhiko Okumura, Toshiba Corporation

Co-Chair: David Hermann, Volvo Car Corporation AB

- 34.1: **Invited Paper: Future AR-HUD System**
Younghoon Han, Hyundai Mobis, Yongin, South Korea
- 34.2: **Dual-Focal-Plane Augmented-Reality Head-Up Display Using Polarization Multiplexing**
Zong Qin, Sun Yat-sen University, Guangzhou, China
- 34.3: **Vehicle-Mounted Projection Display with Local Dimming Effect**
Weining Chi, BOE Optoelectronics Technology Co., Ltd., Beijing, China
- 34.4: **Late-News Paper: Augmented Information by Graphics Pillar-to-Pillar RGB LED Display at the Base of the Windscreen: Design, Measurements & Evaluation**
Karlheinz Blankenbach, Pforzheim University Display Lab, Pforzheim, Germany

Session 35: Novel Technologies and Systems (Emerging Technologies and Applications)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 402AB

Chair: Jim Zhuang, Meta

Co-Chair: Maple Peng, Meta

- 35.1: **Retroreflective ZBD LCD for High-Brightness Digital License Plate**
Guy Bryan-Brown, New Vision Display, Malvern, United Kingdom
- 35.2: **Front-Light Source Module Adapted for Reflective LCD**
Tingxiu Hou, Beijing BOE Optoelectronics Technology Co. Ltd., Beijing, China
- 35.3: **Metasurface-Based Color Filter with Optical Cavity for High Color Purity Displays**
Yun Seon Do, Kyungpook National University, Daegu, South Korea
- 35.4: **Carbon Nanotube Thin-Film Transistors for Active-Matrix Micro-LED Display – Device Performances, Bias Stress Stability and Compact Modeling**
Yujia Gong, Peking University, Beijing, China

Session 36: Glasses-Free 3D (AR/VR/MR / Display Systems)

Wednesday, May 24, 2023 / 10:40 AM - 11:40 AM / Room 408A

Chair: Shinichi Uehara, AGC Inc.

Co-Chair: Zong Qin, Sun Yat-Sen University

- 36.1: **360-Degree Transparent Light-Field Display with Highly Directional Holographic Screens for Fully Volumetric 3D Video Experience**
Tomoharu Nakamura, Sony Group Corporation, Atsugi, Japan
- 36.2: **Coarse Integral Imaging Displays with Interleaved Fresnel Lenses**
Hideki Kakeya, University of Tsukuba, Tsukuba, Japan
- 36.3: **Design and Analysis of Brightness Enhancement Integral Imaging-Based 3D Light-Field Normal Display and Optical See-Through Light-Field Display by Discrete Lenslet Array**
Chia-Yuan Chang, National Taiwan University, Taipei, Taiwan Roc

Session 37: MicroLED Manufacturing (Emissive, Micro-LED, and Quantum-Dot Displays / Display Manufacturing)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 408B

Chair: Chris Bower, X Display Company

Co-Chair: Chiwoo Kim, APS Holdings

- 37.1: **Invited Paper: Manufacturing Readiness of High-Efficiency and Low-Cost MicroLED Displays**
Mingwei Zhu, Applied Materials, Santa Clara, CA US
- 37.2: **Distinguished Paper: Efficiency Enhancement of Submicron-Size Light-Emitting Diodes by Triple Dielectric Layers**
Hyunmin Cho, Samsung Display Co., Ltd., Yongin, South Korea
- 37.3: **Defect Detection of MicroLED Displays by Simultaneous Visual and Thermal Imaging**
Mikyung Lim, Korea Institute of Machinery and Materials (KIMM), Daejeon, South Korea
- 37.4: **Invited Paper: Toward Small, Ultra-High-Definition MicroLED Displays Using Monolithic Vertically Stacked RGB LEDs**
Yasufumi Fujiwara, Osaka University, Osaka, Japan

Session 38: Smart Windows (Outdoor Displays / Display Systems / Liquid Crystal Technology)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 406

Chair: Samantha Phenix, Phenix Consulting

Co-Chair: *David Eccles*

- 38.1: **Invited Paper:** Smart Glass Application of Display Technology
Anthony Slack, eLstar Dynamics, Eindhoven, Netherlands
- 38.2: **Ubiquitous Display with High Transparency Phosphor-Dot Projection Film**
Cheng-Huan Chen, National Yang Ming Chiao Tung University, Hsinchu, Taiwan Roc
- 38.3: **Design of Random Depolarization Films Based on Modulation Transfer Function Measurements**
Shizuki Sasaki, Keio University, Kawasaki, Japan
- 38.4: **High Transmittance MiniLED Panel with Improved See-Through Imaging Quality**
Zhiqiang Xu, BOE, Beijing, China

Session 39: Optical Fingerprint Sensing Displays (*Interactive Displays and Systems*)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 404

Chair: *Martin Grunthaner, Apple*

Co-Chair: *Hiroshi Haga, Tianma Japan*

- 39.1: **Optical Structure of In-Cell Fingerprint Identification Unit for OLED Display with Thick Cover Glass**
Cheng-Huan Chen, National Yang Ming Chiao Tung University, Hsinchu, Taiwan Roc
- 39.2: **Ultra-Thin Integration of Optical Array Sensors with Displays and Any Transparent Surface for Fingerprint Imaging and Beyond: Toward a Universal Sensor for Displays**
Chi-Hao Lin, Harvest Intelligence Technology Co., Tainan, Taiwan Roc
- 39.3: **Pinhole Matrix Fingerprint-on-Display Technology for CFOT OLED Display**
Yang Zeng, Shanghai Tianma Microelectronics, Shanghai, China
- 39.4: **Analysis of Large-Area Optical Fingerprint Recognition Technology Under OLED Screen**
Guiyang Zhang, TCL China Star Optoelectronics Technology Co., LTD (TCL CSOT), Wuhan, China

Session 40: Novel TFTs (*Active Matrix Devices*)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 403A

Chair: *Norbert Fruehauf, University of Stuttgart*

Co-Chair: *Hyun Jae Kim, Yonsei University*

- 40.1: **Invited Paper:** Thin-Film Transistor Modeling
John Wager, Oregon State University, Corvallis, OR US
- 40.2: **Invited Paper:** High-Performance p-Type TFT with Metal Halide Semiconductors
Myung-Gil Kim, Sungkyunkwan University, Suwon, South Korea
- 40.3: **Distinguished Paper:** Reliable Low-Power High-Performance Low-Temperature Polycrystalline Silicon Thin-Film Transistor Technologies in Bottom Gate-Controlled Device Architectures for AMOLED Displays
Keunwoo Kim, Samsung Display, Yongin, South Korea
- 40.4: **Invited Paper:** Self-Aligned Top-Gate Amorphous In-Ga-Zn-O Thin-Film Transistors with Hafnium-Induced Source/Drain Regions
Jiye Li, Peking University, Shenzhen, China

Session 41: OLED Materials II (*OLEDs*)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 403B

Chair: *Sven Zimmermann, Novalcd GmbH*

Co-Chair: *Nicholas Thompson, Universal Display Corporation*

- 41.1: **Invited Paper:** Highly Efficient and Stable Deep-Blue Organic Light-Emitting Diode Using Phosphor-Sensitized Thermally Activated Delayed Fluorescence
Changwoong Chu, Samsung Display, Yongin, South Korea
- 41.2: **Invited Paper:** Recent Progress in Boron-Based MR-TADF Materials
Takuji Hatakeyama, Kyoto University, Kyoto, Japan
- 41.3: **Efficient Pure-Blue Hyperfluorescence OLEDs with Donor-Acceptor-Donor Type Thermally Activated Delayed Fluorescence Sensitizer**
Young Hun Jung, Kyung Hee University, Seoul, South Korea
- 41.4: **Multi-Resonance Thermally Activated Delayed Fluorescence Emitters for Pure-Blue OLEDs with Suppressed Efficiency Roll-Off**
Min Chul Suh, Kyung Hee University, Seoul, South Korea

Session 42: Automotive Image Quality (*Automotive/Vehicular Displays and HMI Technologies*)

Wednesday, May 24, 2023 / 10:40 AM - 12:00 PM / Room 411

Chair: *Rashmi Rao, Harman International*

Co-Chair: *Eric Margulies, Universal Display Corporation*

- 42.1: **Perceptual Judgements of Simulated Low Temperatures in LCD-Based Vehicle Displays**
Kjell Brunnström, RISE Research Institutes of Sweden AB, Kista, Sweden
- 42.2: **Automotive Image Enhancement**
Paul Weindorf, Visteon Corporation, Van Buren Twp., MI US
- 42.3: **Impact of Resolution of Image Condensation and Matrix BLU on Power Saving, Contrast Enhancement, and Local Dimming Processor Complexity for Automotive Applications**
Ramazan Ayasli, University of Saarland, Saarbrücken, Germany
- 42.4: **Automotive Liquid-Crystal Display Using MiniLED Backlight Managed by Flexible Local Dimming System**
Noriaki Yamaguchi, Sharp Display Technology Corporation, Nara, Japan

Session 43: Display Manufacturing: TFT Processing (*Display Manufacturing*)

Wednesday, May 24, 2023 / 3:30 PM - 4:50 PM / Room 402AB

Chair: *Tian Xiao, NEXT Biometrics Inc.*

Co-Chair: *Andriy Romanyuk, Glas Troesch AG*

- 43.1: **Invited Paper:** The Application and Future Development Trend of Oxide Technology in the Meta-Universe

- Ce Ning, BOE Technology Group Co., Ltd., Beijing, China
- 43.2: **Distinguished Paper: High-Performance, Coplanar Amorphous IGZO TFTs by Spray Pyrolysis on PI Substrate for Low Cost Manufacturing of Foldable AMOLED Display**
Jin Jang, Kyunghee University, Seoul, South Korea
- 43.3: **AMOLED Display Sandy Mura Study and Improvement**
Haoyuan Fan, BOE Technology Group Co., Ltd., Mianyang, China
- 43.4: **Ultra-High On-Current Vertical Field-Effect Transistor with Submicron Channel Length of 0.5 μm Using CAAC-IGZO**
Masataka Nakada, Semiconductor Energy Laboratory Co., Ltd., Tochigi, Japan

Session 44: Light-Field and HDR for AR/VR/MR (AR/VR/MR / Display Systems)

Wednesday, May 24, 2023 / 3:30 PM - 4:50 PM / Room 408A

Chair: Nikhil Balram, Mojo Vision

Co-Chair: Shinichi Uehara, AGC Inc.

- 44.1: **Invited Paper: Review of Time-Multiplexed Methods for High-Performance Head-Mounted Light-Field Displays**
Hong Hua, The University of Arizona, Tucson, AZ US
- 44.2: **Viewing Window Extension in Integral-Imaging-Based Head-Mounted Light-Field Displays Using Time-Multiplexed Method**
Cheng-Ting Huang, The University of Arizona, Tucson, AZ US
- 44.3: **Invited Paper: Metalens Array for Integral-Imaging-Based Near-Eye Display**
Jian-Wen Dong, Sun Yat-Sen University, Guangzhou, China
- 44.4: **A Novel DPU Architecture for HDR Display for AR, VR, and MR**
Deoksoo Park, Samsung Electronics, Hwaseong, South Korea

Session 45: MicroLED Displays (Emissive, Micro-LED, and Quantum-Dot Displays)

Wednesday, May 24, 2023 / 3:30 PM - 5:10 PM / Room 408B

Chair: Qun Yan, Fuzhou University

Co-Chair: Michele Ricks, EMD Electronics

- 45.1: **Invited Paper: Status of the MicroLED Display Industry**
Eric Virey, Yole Intelligence, Portland, OR US
- 45.2: **14.6-in. 202ppi Rollable MicroLED Display with Color-Conversion Technology**
Chan-Jui Liu, AUO Corporation, Hsinchu, Taiwan Roc
- 45.3: **Invited Paper: MicroLED Display Applications and Roadmap of Technology Development by PixeLED Solutions**
Ying-Tsang Liu, PlayNitride Display Co., Ltd., Zhunan Township, Miaoli County, Taiwan Roc
- 45.4: **MicroLED Display Life Cycle Assessment**
Antonin Holo, CEA-Leti, Grenoble, France
- 45.5: **Invited Paper: MicroLED Displays for Smartwatch and Smartphone Applications**
Reza Chaji, VueReal Inc, Waterloo, ON Canada

Session 46: Digital Signage (Outdoor Displays / Flexible Displays and e-Paper / Display Systems)

Wednesday, May 24, 2023 / 3:30 PM - 4:50 PM / Room 406

Chair: Karlheinz Blankenbach, Pforzheim University

Co-Chair: Samantha Phenix, Phenix Consulting

- 46.1: **Invited Paper: Large-Scale Outdoor Display Systems: Applications and Technology Trends**
Brett Wendler, Daktronics, Inc., Watertown, SD US
- 46.2: **Invited Paper: Outdoor Displays for Industrial and Digital Signage Applications**
Alexander Trica, Data Modul AG, Munich, Germany
- 46.3: **Invited Paper: Ultra-Low-Power Color e-Paper Signage Displays for Outdoor Use**
Ian French, E Ink Corporation, Billerica, MA US
- 46.4: **Invited Paper: Digital-out-of-Home Displays that Run Forever on Solar Energy**
Doeke Oostr, Etulipa, Eindhoven, Netherlands

Session 47: Emerging Optical Sensing (Interactive Displays and Systems / Emerging Technologies and Applications)

Wednesday, May 24, 2023 / 3:30 PM - 4:50 PM / Room 404

Chair: Dr. John Zhong, Apple, Inc.

Co-Chair: Susan Jones, Nulumina Corp.

- 47.1: **Ambipolar Gap-Type a-Si-TFT Circuit for a Color Ambient-Light Sensor**
Chen-Yu Lin, National Yang Ming Chiao Tung University, Hsinchu, Taiwan Roc
- 47.2: **A TFT-Based Photosensitive Device**
Meng Zhao Hui, BOE Technology Group Co., Ltd, Beijing, China
- 47.3: **In-Cell Ambient Light Sensors (ALSs) LCD Integration Using a-Si TFT Photo-Transistor and Four-Mask Process Architecture Technology**
An-Thung Cho, ChuZhou HKC Optoelectronics Technology Co., Ltd., ChuZhou, China
- 47.4: **Highly Sensitive Lateral Poly-Si PIN Photodiode by Blue Laser Annealing of 400nm Amorphous Si for Near-Infrared Light Sensing**
Jiseob Lee, Kyunghee University, Seoul, South Korea

Session 48: Short Channel Oxide TFTs (Active Matrix Devices)

Wednesday, May 24, 2023 / 3:30 PM - 4:50 PM / Room 403A

Chair: Prof. Man Wong, The Hong Kong University of Science & Technology

Co-Chair: Kwon-Shik Park, LG Display

- 48.1: **Invited Paper: Oxide Semiconductor Thin-Film Transistors with Deep Submicron Channel Fabricated with Hyperlithography**
Sung Haeng Cho, Electronics and Telecommunications Research Institute, Daejeon, South Korea
- 48.2: **Vertical Oxide Semiconductor Transistor Suitable for High-Resolution OLED Display**
Motoharu Saito, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan
- 48.3: **In-Ga-Zn-O Synaptic Transistor with 1 μm Channel Length for Neuromorphic Computing**

Junhyeong Park, Seoul National University, Seoul, South Korea

- 48.4: **Late-News Paper:** Evaluation of a-IGZO Channel Characteristics to Improve the Performance of Oxide TFT
Bohwa Kim, Samsung Display, Yongin, South Korea

Session 49: OLED Materials III (OLEDs)

Wednesday, May 24, 2023 / 3:30 PM - 4:30 PM / Room 403B

Chair: Jang Hyuk Kwon, Kyung Hee University

Co-Chair: Chihaya Adachi, Kyushu University

- 49.1: **Invited Paper:** Perovskite Nanocrystals for High-Efficiency, Stable, and Large-Area Light-Emitting Diodes
Tae-Woo Lee, Seoul National University, Seoul, South Korea
- 49.2: WITHDRAWN
Zuo-Quan Jiang, Soochow University, Jiangsu, China
- 49.3: **Invited Paper:** Blue-Emitting Tetradentate Pt Complexes for Displays and Lighting Applications
Jian Li, Arizona State University, Tempe, AZ US
- 49.4: **Novel Composition of Black Bank for OLED**
JunKi Kim, Duksan Neolux, Cheonan, South Korea

Session 50: Automotive Panel Optics (Automotive/Vehicular Displays and HMI Technologies)

Wednesday, May 24, 2023 / 3:30 PM - 4:50 PM / Room 411

Chair: Casey Kang, Corning Incorporated

Co-Chair: Taewoong Kim, Samsung Display Co.

- 50.1: **Full-Area Local Dimming Switchable Privacy Solution with Color Compensation**
Pawel Murzyn, Visteon, Chelmsford, United Kingdom
- 50.2: **Optical Decoration Film**
Cyun-Tai Hong, BenQ Materials Corp., Taoyuan, Taiwan Roc
- 50.3: **Resolution Lossless Dual-View Displays Based on Direction Backlight and Time Multiplexing**
Yongle Qi, Beijing BOE Display Technology Co., Ltd., Beijing, China
- 50.4: **Late-News Paper:** Multi-Domain Retarders for Eliminating Off-Axis Reflection Color Differences in Automotive OLED Displays
Tae-Hoon Choi, Korea Automotive Technology Institute, Cheonan, South Korea

Session 51: Advances in Display Manufacturing Equipment (Display Manufacturing)

Thursday, May 25, 2023 / 9:00 AM - 10:20 AM / Room 402AB

Chair: Toshiaki Arai, JOLED Inc

Co-Chair: Greg Gibson, nTact

- 51.1: **Distinguished Paper:** High Precision and High Stability Inkjet Printing Technology for QD Color-Conversion Filter Formation
Yoshida Hidehiro, Panasonic Production Engineering, Osaka, Japan
- 51.2: **Invited Paper:** Developing a Platform for Creating Waveguide Combiners for AR Headsets and Metasurface-Based Optics
Robert Visser, Applied Materials Inc., Santa Clara, CA US
- 51.3: **Gen. 2 Copper Thin-Film Dry-Etching Equipment via ECR Plasma Source**
Chiwoo Kim, APS Holdings Corporation, Hwasung, South Korea
- 51.4: **Collimated Organic Molecular Beam Made by Triple-Nozzle Evaporator**
Sungmoon Kim, DepoLab, Gwangmyeong, South Korea

Session 52: Emerging Optics for AR/VR/MR (AR/VR/MR / Emerging Technologies and Applications)

Thursday, May 25, 2023 / 9:00 AM - 10:30 AM / Room 408A

Chair: Abhishek Srivastava, Hong Kong University of Science & Technology

Co-Chair: Vincent Gu, Apple, Inc.

- 52.1: **Ultracompact Virtual-Reality System**
Junyu Zou, University of Central Florida, Orlando, FL US
- 52.2: **Invited Paper:** ChromaCorrect: Prescription Correction in Virtual-Reality Headsets Through Perceptual Guidance
Jeanne Beyazian, University College London, London, United Kingdom
- 52.3: **Field-Sequential Color LCD for Enabling 60ppd and 100°-FoV VR Displays**
Zhiyong Yang, University of Central Florida, Orlando, FL US
- 52.4: **Distinguished Paper:** Switchable Polarization Volume Gratings for Augmented-Reality Waveguide Displays
Yannanqi Li, University of Central Florida, Orlando, FL US
- 52.5: **Late-News Paper:** Thin and Lightweight Head-Mounted Displays with Holographic Optics and Polarized Laser Backlights Using an Inverted Wedge-Shaped Light-Guide Plate
Jin Hirosawa, Japan Display Inc., Mobarra, Japan

Session 53: MicroLED Processing (Emissive, Micro-LED, and Quantum-Dot Displays)

Thursday, May 25, 2023 / 9:00 AM - 10:30 AM / Room 408B

Chair: Francois Templier, CEA-LETI

Co-Chair: Yajie Dong, University of Central Florida

- 53.1: **Invited Paper:** Enhanced Performance of III-Nitride-Based Light-Emitting Diodes Through Novel Band Engineering and Fabrication Technology
Xiaohang Li, King Abdullah University of Science and Technology (KAUST), Jeddah, Saudi Arabia
- 53.2: **Mini LED Emissive Display Product with Pitch 0.5mm Based on MIP Chips**
Qi Fan, BOE MLED Technology Co., Ltd., Beijing, China
- 53.3: **High-Efficiency MicroLED Displays Enabled Through PulseForge Assisted Die Transfer**
Pranav Gavirneni, University of Waterloo, Waterloo, ON Canada
- 53.4: **The Path of 300 mm GaN-on-Si Epiwafers into Silicon Semiconductor Fabs**
Atsushi Nishikawa, ALLOS Semiconductors GmbH, Dresden, Germany
- 53.5: **Late-News Paper:** High-Resolution Optical Inspection of NR LEDs-Based Assembly and Their Evaluation for Display Applications

Session 54: Optical Sensing Displays (*Sensors Integration and Multi-Functional Displays / Interactive Displays and Systems*)

Thursday, May 25, 2023 / 9:00 AM - 10:00 AM / Room 406

Chair: *Jeff Han, Consultant*

Co-Chair: *Ion Bitu, Google LLC*

- 54.1: **Invited Paper:** Through OLED Display Proximity Sensing
Mark Winkler, Apple Inc, Cupertino, CA US
- 54.2: **Invited Paper:** Novel Display Applications Beyond OLED: All-in-One Sensor Display
Sungchan Kim, Samsung Display Co. Ltd., Yongin, South Korea
- 54.3: **Patterned Liquid-Crystal Polymer on Polarized Ambient Light Sensor**
Yi Hung, Liqxtal Technology Inc., Tainan, Taiwan Roc

Session 55: High Performance Displays (*Display Systems*)

Thursday, May 25, 2023 / 9:00 AM - 10:20 AM / Room 404

Chair: *Brian Berkeley, Highlight Display, LLC*

Co-Chair: *Hidekazu Hatanaka, Ushio Inc.*

- 55.1: **Invited Paper:** Apple Liquid Retina XDR Displays with MiniLEDs
Jun Qi, Apple Inc, Cupertino, CA US
- 55.2: **Invited Paper:** Quantum-Dot Color Conversion for Displays
Ilan Jen-La Plante, Nanosys, Inc., Milpitas, CA US
- 55.3: **Invited Paper:** From Smallest AR Glasses to Mainstream Display Projection: Latest Advances of Visible LED and Laser Solutions
Stephan Haneder, ams-OSRAM International GmbH, Regensburg, Germany
- 55.4: **Invited Paper:** Monolithic MicroLED Display for AR Applications
Peng Chen, Jade Bird Display Limited, Shanghai, China

Session 56: Extreme LCDs (*Liquid Crystal Technology*)

Thursday, May 25, 2023 / 9:00 AM - 10:40 AM / Room 403A

Chair: *Dr Akihiro Mochizuki, I-CORE Technology, LLC*

Co-Chair: *Jenn Jia Su, AU Optronics Corporation*

- 56.1: **Invited Paper:** Ultra-High Frame-Rate ADS LCDs
Zhonghao Huang, BOE Technology Group Co., Ltd., Beijing, China
- 56.2: **Invited Paper:** World's First 1Hz Driving Fringe-Field Switching (FFS) LCD for Power Saving
Seung-Hwa Baek, LG Display, Paju-si, Gyeonggi-do, South Korea
- 56.3: **Invited Paper:** Immersive Gaming Display: 49-in. Ultra-Wide (32:9) Curve (R=1,000mm) and High Frame Rate (360Hz)
Chien-Huang Liao, AUO Corporation, Hsinchu, Taiwan Roc
- 56.4: **Exploration of Ultra-Large 16K High-Resolution Technology**
Chunyu Li, BOE Technology Group Co., Ltd., Fuzhou, China
- 56.5: **HTR-ADS: A Novel Ultra-High-Transmittance Display Mode**
Xin Zhou, Hefei BOE Display Technology Co., Ltd., Hefei, China

Session 57: OLED Physics I (*OLEDs*)

Thursday, May 25, 2023 / 9:00 AM - 10:00 AM / Room 403B

Chair: *Denis Kondakov, DuPont*

Co-Chair: *Yuan-Chun Wu, China Star Optoelectronics*

- 57.1: **Accelerating Next-Generation Display Materials Development with a Smart Digital Chemistry Platform**
Christopher Brown, Schrödinger, Inc., New York, NY US
- 57.2: **Polarization-Induced Exciton-Polaron Quenching and Efficiency Loss in OLEDs: Role of Stack Architecture and Processing Conditions**
Russell Holmes, University of Minnesota, Minneapolis, MN US
- 57.3: **Invited Paper:** Using Digital Twins of OLEDs to Quantify the Impact of Molecular Properties on Device Performance for Rational Design
Tobias Neumann, Nanomatch GmbH, Karlsruhe, Germany

Session 58: Flexible Displays (*Flexible Displays and e-Paper*)

Thursday, May 25, 2023 / 9:00 AM - 10:00 AM / Room 411

Chair: *Jeong-Ik Lee, ETRI*

Co-Chair: *Joon Young Yang, LG Display Co. Ltd.*

- 58.1: **Research on 360-Degree Folding AMOLED Display and Optimization Design of Terminal Product by FEA**
Baofeng Sun, BOE, Beijing, China
- 58.2: **Structurally Anisotropic Backing Sheets for Rollable-Foldable Display Modules**
William Hambrun, Palo Alto, CA US
- 58.3: **Late-News Paper:** Transparent Organic Thin-Film Transistors for Wearable Bioelectronics
Chen Jiang, Tsinghua University, Beijing, China

Session 59: Improved Light Management (*Display Manufacturing*)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 402AB

Chair: *Dr. Andriy Romanyuk, Glas Troesch AG*

Co-Chair: *Joerg Winkler, PLANSEE SE*

- 59.1: **Low-Reflection Material Design and Application in LCD Panel**
Chang Eun Kim, LG Display, Seoul, South Korea
- 59.2: **Diffuse Reflected Light Control for Reflective Tablet Display by Combining Use of Anisotropic and Isotropic Light-Diffusing Films**

- Hiroki Fukushima, LINTEC Corporation, Warabi, Japan
59.3: **Application of 3D Printing in the Reflector of Glass-Based MiniLED Backlight**
Xing Liu, BOE MLED Technology Co., Ltd., Hefei, China

Session 60: Subsystems for AR/VR/MR (AR/VR/MR / Emerging Technologies and Applications / Liquid Crystal Technology)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 408A

Chair: Ian Underwood, University of Edinburgh

Co-Chair: Linghui Rao, Meta

- 60.1: **Invited Paper: Emerging Microdisplay Technologies for AR/VR Applications**
Shin-Tson Wu, University of Central Florida, Orlando, FL US
60.2: **Distinguished Paper: High-Efficiency Folded Optics for Near-Eye Displays**
Zhenyi Luo, University of Central Florida, Orlando, FL US
60.3: **Invited Paper: Liquid-Crystal Optics for AR/VR/MR Near-Eye Displays**
Yuge Huang, Reality Labs, Meta Platforms, Inc., Redmond, WA US
60.4: **Distinguished Paper: Novel Pancake-Based HMD Optics to Improve Light Efficiency**
Naru Usukura, Sharp Display Technology Corporation, Nara, Japan

Session 61: Quantum Dot Displays I (Emissive, Micro-LED, and Quantum-Dot Displays)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 408B

Chair: Yong Seog Kim, Hongik University

Co-Chair: Keunchan Oh, Samsung Display

- 61.1: **Invited Paper: Development of Active-Matrix NanoLED Display with Cadmium-Free QDs Patterned by Photolithography Process in the Atmosphere**
Shota Okamoto, Sharp Display Technology Corporation, Tenri, Japan
61.2: **Distinguished Paper: Development of Inkjet Printing Technology for 55-in. 8K AMQLED Display**
Zhuo Chen, BOE Technology Group Co., Ltd., Beijing, China
61.3: **Method for Controlling Surface Energy of Bank Surfaces to Fabricate High-Thickness Inkjet-Printed QD Color Conversion Layer**
Sang youn Lee, Korea Institute of Industrial Technology, Ansan, South Korea
61.4: **All-Inkjet-Printed EL-QD Display with Improved Efficiency and Lifetime**
Jaekook Ha, Samsung Display Company, Yongin, South Korea

Session 62: Non-Visible Spectrum Optical Sensing (Sensors Integration and Multi-Functional Displays / Interactive Displays and Systems / Active Matrix Devices / Emissive, Micro-LED, and Quantum-Dot Displays)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 406

Chair: Ying Zheng, Microsoft

- 62.1: **Distinguished Paper: Ultraviolet Photodetectors and Readout Based on a-IGZO Semiconductor Technology**
Yannick Schellander, University of Stuttgart, Stuttgart, Germany
62.2: **Novel TFT Short-Wave Infrared Sensor Based on Colloidal Quantum-Dot Technology**
Dexi Kong, Beijing BOE Optoelectronics Technology Co., Ltd., Beijing, China
62.3: **Infrared Sensitive Thin-Film Phototransistor Made on Glass Substrate for Active-Matrix Sensing Application**
Yi-Cheng Yuan, National Yang Ming Chiao Tung University, Hsinchu, Taiwan Roc
62.4: **Invited Paper: Visible-Blind Infrared Upconversion Devices for Image Sensing**
Shun-Wei Liu, Ming Chi University of Technology, New Taipei City, Taiwan Roc

Session 63: Backlighting Technologies (Display Systems)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 404

Chair: Dr Daming Xu, Apple Inc

Co-Chair: K Kälantär, Global Optical Solutions

- 63.1: **Integrated Ultra-Thin Direct-Lit LCD Backlight Using Glass Components**
Seung-yong Park, Corning Technology Center Korea, Asan, South Korea
63.2: **Nanowire Grid Polarizer and Meta-Surface Textures Integrated with Highly Efficient, Single Polarized Light-Emitting Diode**
Xianqin Meng, BOE Technology Group Co., Ltd., Beijing, China
63.3: **A Small-Aspect-Ratio High-Voltage MiniLED Solution for Glass-Based MLED Backlighting**
Shan Wei Yang, BOE MLED Technology Co., Ltd., Beijing, China
63.4: **A New Single X-Wire Active-Matrix MiniLED Backlight with Motion Blur Reduction for LCD TVs**
Hansai Ji, Xianxin Technology, Beijing, China

Session 64: LC Materials (Liquid Crystal Technology)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 403A

Chair: Michael Wittek, Merck KGaA

Co-Chair: Koichi Miyachi, JSR Corporation

- 64.1: **Invited Paper: XtraFast: New LC Mixture Developments for Gaming Applications**
Ki-Sun Kwon, Merck performance Materials Ltd., Pyeongtaek-si, Gyeonggi-do, South Korea
64.2: **Distinguished Paper: Novel Cholesteric Liquid-Crystal Films Create Angle-Insensitive Reflective Colors**
Haruka Sano, FUJIFILM Corporation, Kanagawa, Japan
64.3: **Invited Paper: Latest Developments in Liquid Crystals for RF Applications**
Matthias Jost, Merck KGaA, Darmstadt, Germany
64.4: **Invited Paper: High-Contrast-Ratio ADS LCD Using Negative Liquid-Crystal Material**
Lei Guo, BOE Technology Group Co., Ltd., Beijing, China

Session 65: OLED Physics II (OLEDs)

Thursday, May 25, 2023 / 10:40 AM - 11:40 AM / Room 403B

Chair: *Nicholas Thompson, Universal Display Corporation*

Co-Chair: *Jang Hyuk Kwon, Kyung Hee University*

65.1: **Invited Paper:** **Diverse Effects of Defects on the Performance of Organic Light-Emitting Diodes**

Jaesang Lee, Seoul National University, Seoul, South Korea

65.2: **Invited Paper:** **OLEDs with Doublet Emission Using Radicals**

Emrys Evans, Swansea University, Swansea, United Kingdom

65.3: **Kinetic Pathways of Excitons and Polarons Governing Device Degradation in Exciplex-Forming Co-Host-Based Organic Light-Emitting Diodes**

Kyung Hyung Lee, Sungkyunkwan University, Suwon, South Korea

Session 66: Mechanical Strength and Reliability (*Flexible Displays and e-Paper*)

Thursday, May 25, 2023 / 10:40 AM - 12:00 PM / Room 411

Chair: *Arokia Nathan, Darwin College, University of Cambridge*

Co-Chair: *Jennifer Lin, AU Optronics*

66.1: **Invited Paper:** **Flexible Yet Robust Cover Window with Enhanced Bending Stiffness**

Yong-Cheol Jeong, KITECH, Ansan, South Korea

66.2: **Highly Transparent, Colorless Optical Film with Outstanding Mechanical Strength and Folding Reliability Using Mismatched Charge-Transfer Complex Intensification**

Sung Woo Hong, Korea Institute of Industrial Technology, Cheonan, South Korea

66.3: **Effective Foldable AMOLED Structure with Bendability and Impact Resistance**

Mayuko Sakamoto, Sharp Display Technology Corporation, Nara, Japan

66.4: **Late-News Paper:** **Z-Type Multi-Foldable AMOLED for High Durability and Superior Foldability**

Suk Choi, LG Display, Seoul, South Korea

Session 67: Laser Processing (*Display Manufacturing*)

Thursday, May 25, 2023 / 1:30 PM - 2:50 PM / Room 402AB

Chair: *Dr. Chiwoo Kim, APS Holdings*

Co-Chair: *Dr. Sangyeol Kim, Samsung Display*

67.1: **Laser Process for Full-Screen OLED Displays**

Eonseok Oh, Samsung Display, Yongin, South Korea

67.2: **Activation of Doped Silicon Film Using Semiconductor Blue-Light Diode Laser Annealing**

Yang Yingbao, V-Technology Co., Ltd., Yokohama, AL Japan

67.3: **Numerical Simulation for GaN-based MicroLED Laser-Induced Forward Transfer**

Oliver Haupt, Coherent LaserSystems GmbH & Co. KG, Göttingen, Germany

67.4: **Uniform Polycrystalline Si Films Obtained via the Fiber-Laser-Based Spot-Beam-Annealing Method**

Jayoung Park, Columbia University, New York, NY US

Session 68: Waveguide Technologies for AR (*AR/VR/MR / Display Systems*)

Thursday, May 25, 2023 / 1:30 PM - 2:30 PM / Room 408A

Chair: *Brian Schowengerdt, Meta*

Co-Chair: *Nikhil Balram, Mojo Vision*

68.1: **Invited Paper:** **A Waveguide-Type Retinal Scan AR Display with Pupil Expansion System**

Akira Yoshikaie, Sony Group Corporation, Kanagawa, Japan

68.2: **Distinguished Paper:** **Design Optimization of Polarization Volume Gratings for Full-Color Waveguide-Based AR Displays**

Yuqiang Ding, University of Central Florida, Orlando, FL US

68.3: **A Multi-Focal Waveguide Near-Eye Display Based on a Tunable Pancharatnam-Berry Phase Lens**

Bo Wang, Shanghai Jiao Tong University, Shanghai, China

Session 69: Quantum Dot Displays II (*Emissive, Micro-LED, and Quantum-Dot Displays*)

Thursday, May 25, 2023 / 1:30 PM - 2:50 PM / Room 408B

Chair: *Ruiqing Ma, Nanosys*

Co-Chair: *Xiao Wei Sun, Southern University of Science and Technology*

69.1: **Invited Paper:** **Improving Efficiency and Brightness in Colloidal Quantum-Dot Light-Emitting Diodes**

Jeonghun Kwak, Seoul National University, Seoul, South Korea

69.2: **Narrow-Band Quantum Rods for Healthy Solid-State Lighting**

Chengbin Kang, Hong Kong University of Science and Technology, Hong Kong, Hong Kong

69.3: **Late-News Paper:** **Enhanced Performance of Quantum Dot Light Emitting Diode via Optimizing PVK and Poly-TPD Mixture Ratio for Hole Transport Layer**

Hyobin Kim, Sungkyunkwan University, Suwon, South Korea

69.4: **Late-News Paper:** **Quantum Dot/Organic Nanohybrids for InP-based QD-LEDs and Their Patterning via Electrohydrodynamic Jet Printing**

Yohan Kim, Fraunhofer Institute for Applied Polymer Research IAP, Potsdam, Germany

Session 70: RF and Antenna on Display Applications (*Sensors Integration and Multi-Functional Displays / Emerging Technologies and Applications*)

Thursday, May 25, 2023 / 1:30 PM - 2:30 PM / Room 406

Chair: *Fang-Cheng Lin, Apple, Inc.*

Co-Chair: *Ian Underwood, University of Edinburgh*

70.1: **Antenna-on-Display (AoD) for Smartphones: Role, Main Requirements, and Promising Evolution**

Huan-Chu Huang, Visionox Technology Inc., Langfang, China

70.2: **Modification of Pixel Design for NFC Antenna Integrated in LCD Panel**

Dawei Feng, Beijing BOE Optoelectronics Technology Co., Ltd., Beijing, China

70.3: **Tunability of Reconfigurable Intelligent Surface (RIS) using Liquid Crystal According to Various Bias Voltage Levels**

Session 71: Display Visual Comfort (*Applied Vision*)

Thursday, May 25, 2023 / 1:30 PM - 2:50 PM / Room 404

Chair: Takashi Shibata, Tokai University

Co-Chair: Chien-Yu Chen, National Taiwan University of Science & Technology

- 71.1: **Data-Driven and Optics-Inspired Decomposition of Global Pupil Swim in VR/AR for an Improved Perception Model of Motion Discomfort**
Jerry Jia, Meta Reality Labs, Menlo Park, CA US
- 71.2: **Effect of Compensation Method on Visually Induced Motion Sickness for Transparent Window Display**
Chia-Hsun Tu, Electronic and Optoelectronic System Research Laboratories, Industrial Technology Research Institute, Hsinchu, Taiwan Roc
- 71.3: **Effects of Circadian Rhythm, Ambient Illuminance, and Display Content on Comfortable Display Luminance**
Yan Tu, Southeast University, Nanjing, China
- 71.4: **Late-News Paper: Real-Time Visual Fatigue Measurements During Video Watching**
Uijong Ju, Kyung Hee University, Seoul, South Korea

Session 72: Liquid Crystal In-Cell Polarizers (*Liquid Crystal Technology*)

Thursday, May 25, 2023 / 1:30 PM - 2:50 PM / Room 403A

Chair: Lu Lu, Meta Reality Labs

Co-Chair: Matthew Sousa, 3M

- 72.1: **Invited Paper: Improving the Thermal Stability of Coatable Polarizers Through Materials Optimization**
Youyou Li, Wuhan China Star Optoelectronics Technology Co., Ltd., Wuhan, China
- 72.2: **Invited Paper: Color-Conversion Liquid-Crystal Display with an In-Cell Polarizer**
Yiyang Gao, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 72.3: **High-Performance In-Cell Polarizer with Multi-Layer Structure for Liquid-Crystal Displays**
Yuechu Cheng, The Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 72.4: **High-Light-Efficiency and High-Contrast LCD Using Polarizer Louver**
Ryosuke Saigusa, Sharp Display Technology Corporation, Nara, Japan

Session 73: OLED Optics and Simulations (*OLEDs*)

Thursday, May 25, 2023 / 1:30 PM - 2:50 PM / Room 403B

Chair: Yasunori Kijima, Huawei Technologies Japan K.K.

Co-Chair: Yifan Zhang, Apple, Inc.

- 73.1: **Study of MicroOLED Optical Simulation**
wang yingtao, BOE Technology Group Co., Ltd., Beijing, China
- 73.2: **Optimized WRGB OLED Reflection Properties to Enhance Visual Quality in Gaming Displays**
JungHyun Ham, LG Display, Seoul, South Korea
- 73.3: **Study on WAD Improvement of a Large AMOLED Panel**
In Young Chung, Samsung Display Co., Ltd., Yongin, South Korea
- 73.4: **Value and Benefit of Multiscale Material Simulation for OLED R&D: Prediction and Validation of Triplet Emitter Orientation Yielding > 90% In-Plane Transition Dipole Orientation for Ir(ppy)₃ Derivatives**
Falk May, Merck Electronics KGaA, Darmstadt, Germany

Session 74: Stretchable/Flexible AMOLEDs (*Flexible Displays and e-Paper*)

Thursday, May 25, 2023 / 1:30 PM - 2:50 PM / Room 411

Chair: Simon Kang, Apple

Co-Chair: Meng-Ting Lee, Huawei Technologies Co.

- 74.1: **Invited Paper: Highly Stretchable and Shrinkable AMOLED for Free Deformation**
Jong-Ho Hong, Samsung Display, Yongin, South Korea
- 74.2: **Late-News Paper: Top-Emitting Fiber-Based OLEDs with Water Resistance Based on Vacuum Environment for Truly Wearable Displays**
Kyung Cheol Choi, Korea Advanced Institute of Science and Technology (KAIST), Daejeon, South Korea
- 74.3: **Inkjet-Printed High-Performance Organic Thin-Film Transistors**
Shinya Oku, Tosoh Corporation, Yokkaichi, Japan
- 74.4: **Spherical Forming: A Test Method for Stretchability of Flexible OLED from 2D Plane to 3D Surface**
Haoran Wang, BOE Technology Group Co., Ltd., Beijing, China

Session 75: Yield Improvement and Failure Analysis (*Display Manufacturing*)

Thursday, May 25, 2023 / 3:10 PM - 4:30 PM / Room 402AB

Chair: Neetu Chopra, Apple Inc

Co-Chair: Bradley Bowden, Corning Research and Development Corporation

- 75.1: **Real-Time Doping Management of High-Performance Organic Electroluminescence Displays**
Yong-Woon Lim, Samsung Display, Asan-city, South Korea
- 75.2: **Failure Mechanisms and Optimum Methods for Through-Glass Via**
Qichang An, Beijing BOE Sensor Technology Company, Ltd., Hong Kong, China
- 75.3: **Investigation of Influence and Improvement of Dry Etch on Glass Strength**
Zheng Wei Zhu, HeFei BOE Photoelectric Technology Co., Ltd., Hefei, China
- 75.4: **Research on Surface Protective Layer of Cu Pad to Improve Welding Capability for MLED**
Haifeng Hu, HeFei Ruisheng Optoelectronics Technology Co., Hefei, China

Session 76: Holography (*AR/VR/MR / Display Systems*)

Thursday, May 25, 2023 / 3:10 PM - 4:30 PM / Room 408A

Chair: Yifan (Evan) Peng, HKU/Stanford

Co-Chair: David Eccles

- 76.1: **Invited Paper: A Magneto-Optical Spatial Light Modulator with Narrow Pixel Pitch for Holography Application**
Ken-ichi Aoshima, Japan Broadcasting Corp., Tokyo, Japan
- 76.2: **Scalable Real-Time Holography Processor Architecture**
Wonok Kwon, Electronics and Telecommunications Research Institute, Daejeon, South Korea
- 76.3: **A Modified, Unsupervised Vision Transformer Network for High-Fidelity Computer-Generated Holography**
Yan Li, Shanghai Jiao Tong University, Shanghai, China
- 76.4: **Analytical Computer-Generated Holography for Quadrilateral Meshes**
Zong Qin, Sun Yat-sen University, Guangzhou, China

Session 77: Quantum Dot Color Conversion (Emissive, Micro-LED, and Quantum-Dot Displays)

Thursday, May 25, 2023 / 3:10 PM - 4:10 PM / Room 408B

Chair: John Van Derlofske, 3M

Co-Chair: Seth Coe-Sullivan, NS Nanotech

- 77.1: **Invited Paper: Colloidal Quantum-Dot-Based Color-Conversion Layer for MicroLED Arrays**
Chien-Chung Lin, National Taiwan University, Taipei, Taiwan Roc
- 77.2: **Quantum-Dot Color Conversion Achieved by A Novel Structure of Hollow Cylindrical Blue MicroLED**
Wenjun Huang, Southern University of Science and Technology, Shenzhen, China
- 77.3: **Invited Paper: Quantum-Dot Color Conversion In Display Applications: In Pursuit of the Holy Grail**
Igor Nakonechnyi, QustomDot BV, Zwijnaarde, Belgium

Session 78: Piezo Transducers and Applications (Sensors Integration and Multi-Functional Displays / Interactive Displays and Systems)

Thursday, May 25, 2023 / 3:10 PM - 4:10 PM / Room 406

Chair: Jongseo Lee, Google

Co-Chair: Ying Zheng, Microsoft

- 78.1: **Invited Paper: Tactile Scanner as Neuromorphic Skin for Computer Haptics**
Kai Wang, Sun Yat-sen University, Guangzhou, China
- 78.2: **A Flat-Panel-Display-Compatible Ultrasound Platform**
Epimitheas Georgitzikis, imec, Leuven, Belgium
- 78.3: **Piezoresistive Area Sensor with Polymer and Laser-Annealed CNT Mixture on Oxide-TFT Backplane**
Jin Jang, Kyunghee University, Seoul, South Korea

Session 79: HDR + Color (Applied Vision)

Thursday, May 25, 2023 / 3:10 PM - 4:10 PM / Room 404

Chair: Youngshin Kwak, Ulsan National Institute of Science and Technology

Co-Chair: Jang Jin Yoo, LG Display

- 79.1: **Display White According to Surround Ratio**
Seonyoung Yoon, Ulsan National Institute of Science and Technology, Ulsan, South Korea
- 79.2: **Comparison of HDR MicroLED Display and High-Resolution (8K) Impact on Image Quality**
YungKyung Park, Ewha Womans University, Seoul, South Korea
- 79.3: **Image-Quality Change by White-Boost Function of WRGB OLED Display**
Woojae Jung, Ulsan National Institute of Science, Ulsan, South Korea

Session 80: Liquid Crystal Lenses and Beamforming (Liquid Crystal Technology)

Thursday, May 25, 2023 / 3:10 PM - 4:30 PM / Room 403A

Chair: Xiao-Yang Huang, Ebulent Technologies Corp

Co-Chair: Philip Bos, Kent State University

- 80.1: **Invited Paper: Tunable Liquid-Crystal Lens for Dynamic Rx Correction and Accommodation-Convergence Conflict Correction in AR/VR/3D HMDs**
Amit Bhowmick, Kent State University, Kent, OH US
- 80.2: **Liquid-Crystal Surface-Relief Diffractive Lens for Presbyopia**
Guo Lin Hu, Liqxtal Technology Inc., Tainan, Taiwan Roc
- 80.3: **Novel Switchable Half-Wave Retarder with In-Cell Pancharatnam Berry Lens**
Daisuke Minami, Sharp Display Technology Corporation, Nara, Japan
- 80.4: **Invited Paper: Optical Metasurface Beam Steering for Solid-State Lidar 2.0**
Gleb Akselrod, Lumotive, Redmond, WA US

Session 88: e-Paper Displays (Flexible Displays and e-Paper)

Thursday, May 25, 2023 / 3:10 PM - 4:30 PM / Room 403B

Chair: Norihisa Kobayashi, Chiba University

Co-Chair: Chan-Il Park, LG Display Co. Ltd.

- 88.1: **E-Book with Animation-Playing Capability Based on Liquid-Crystal Display Technology**
Pengcheng Liu, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 88.2: **Highly Saturated Color Electrophoretic Display**
HongMei Zang, E Ink California, LLC., Fremont, CA US
- 88.3: **Late-News Paper: IGZO Backplane for Full-Color Electrophoretic Display**
Fumiki Nakano, Sharp Display Technology Corporation, Nara, Japan
- 88.4: **Late-News Paper: Electrochromic Devices with Metallo-Supramolecular Polymers**
Masayoshi Higuchi, National Institute for Materials Science, Tsukuba, Japan

Session 81: Stretchable/Flexible Micro LEDs and AMOLEDs (Flexible Displays and e-Paper / Active Matrix Devices / OLEDs)

Thursday, May 25, 2023 / 3:10 PM - 4:30 PM / Room 411

Chair: *Dr. Joon Young Yang, LG Display Co. Ltd*

Co-Chair: *Yong Taek Hong, Seoul National University*

- 81.1:** **Invited Paper:** **Highly Stretchable Backplane Technologies for Deformable Display Applications**
Masashi Miyakawa, NHK Science & Technology Research Laboratories, Tokyo, Japan
- 81.2:** **Invited Paper:** **Highly Stretchable Color MicroLED Meta-Display Without Image Distortion**
Jae-Hyun Kim, Korea Institute of Machinery and Materials (KIMM), Daejeon, South Korea
- 81.3:** **Design of Narrow-Border Flexible OLED Display Based on Simulation Analysis and Optimization**
Xiaofei Luo, BOE Technology Group Co., Ltd., Beijing, China
- 81.4:** **High-Performance Coplanar Polycrystalline InGaO TFTs on Polyimide Substrate for Foldable AMOLED Display**
Jin Jang, Kyunghee University, Seoul, South Korea

Session 82: Display Measurement For AR/VR/MR (AR/VR/MR / Display Measurement)

Friday, May 26, 2023 / 9:00 AM - 10:20 AM / Room 408A

Chair: *Thomas Fiske, Consultant*

Co-Chair: *Ingo Rotscholl, TechnoTeam Bildverarbeitung GmbH*

- 82.1:** **Distinguished Paper:** **Radially Variant Contrast in Virtual-Reality Headsets**
Chumin Zhao, Food and Drug Administration, Silver Spring, MD US
- 82.2:** **Binocular Vergence and Virtual Focus: A Simple Method for Evaluating the Vergence-Accommodation Conflict in Near-Eye Displays**
Bruce Pixton, U.S. Army C5ISR Center Research & Technology Integration Directorate, Fort Belvoir, VA US
- 82.3:** **Rapid AR/VR Device Eye-Box Measurement Using a Wide-FOV Lens**
Thomas Kerst, OptoFidelity, Tampere, Finland
- 82.4:** **Color Characterization of Virtual-Reality Devices Using Professional- and Consumer-Grade Instruments**
Wei-Chung Cheng, US Food and Drug Administration, Silver Spring, MD US

Session 83: Quantum Dot LED Efficiency (Emissive, Micro-LED, and Quantum-Dot Displays)

Friday, May 26, 2023 / 9:00 AM - 10:20 AM / Room 408B

Chair: *Xiao Wei Sun, Southern University of Science and Technology*

Co-Chair: *Jonathan Steckel, ST Microelectronics*

- 83.1:** **Improved Performance of EL-QD Display Through Surface-Modified QDs and Inorganic Materials Nano Ink**
Yun Ku Jung, Samsung Display Company, Yongin, South Korea
- 83.2:** **Inorganic Ion Treatment of Cd-Free Quantum Dots and Applications to QD-LED with Improved Characteristics**
Keisuke Kitano, Sharp Corporation, Nara, Japan
- 83.3:** **High External Quantum Efficiency of 16.8% Achieved in Quantum-Rod Light-Emitting Diodes**
Kumar Malle, The Hong Kong University of Science and Technology, Hong Kong, China
- 83.4:** **High-Performance Inverted Green and Red InP Quantum-Dot Light-Emitting Diodes with Robust ZnS Electron Transport Interlayer**
Truong Thi Thuy, Kyung Hee University, Dongdaemun, South Korea

Session 84: Liquid Crystal Smart Windows (Liquid Crystal Technology)

Friday, May 26, 2023 / 9:00 AM - 10:20 AM / Room 403A

Chair: *Mr Gang Xu, Jingce Electronics, USA*

Co-Chair: *Michael Wittek, Merck KGaA*

- 84.1:** **Optical Performance and Driving Method of HTN-Mode Dye-Doped Liquid-Crystal Smart Windows**
Sikai Zhang, Beijing BOE Sensor Technology Co. LTD., Beijing, China
- 84.2:** **Flexible Dye Liquid-Crystal Dimming Film for Smart Window**
Chen Juan, Beijing BOE Sensor Technology Co. Ltd., Beijing, China
- 84.3:** **A Novel 2D Diffractive Liquid-Crystal Smart Window Using Single-Sided Engineered Electrode Structure**
Jaewon Huh, Corning Technology Center Korea, Asan, South Korea
- 84.4:** **Switchable Privacy LCD Suitable for the Automotive Super Long-Size Screen**
Kiyoshi Minoura, Sharp Display Technology Corporation, Tenri, Japan

Session 89: Enabling Technologies for AR/VR/MR (AR/VR/MR / Emerging Technologies and Applications / Emissive, Micro-LED, and Quantum-Dot Displays)

Friday, May 26, 2023 / 9:00 AM - 10:00 AM / Room 403B

Chair: *Adi Abileah, Adi - Displays Consulting LLC*

Co-Chair: *John-Ho Hong, Samsung*

- 89.1:** **Late-News Paper:** **Usability of Glove-Based Handling Devices in Virtual Training: Use Case in Automotive Sector**
Sara Buonocore, University of Naples Federico II, Napoli, Italy
- 89.2:** **Late-News Paper:** **Strength-Optimized Laser Cutting of High Refractive Index Wafers for Augmented Reality**
René Liebers, 3D-Micromac AG, Chemnitz, Germany
- 89.3:** **Late-News Paper:** **High-Efficiency and Single-Polarized Light-Emitting Diode with Nano-Wire Grid Polarizer and Meta-Surface Textures**
Xianqin Meng, BOE Technology Group Co., Ltd., Beijing, China

Session 85: Display Manufacturing for AR/VR/MR (AR/VR/MR / Display Manufacturing)

Friday, May 26, 2023 / 10:40 AM - 12:00 PM / Room 408A

Chair: *Yung-Yu Hsu, Meta*

Co-Chair: *Jinsoo Jeong, KETI*

- 85.1:** **Ultra-High-Resolution Corrugated Silicon-Nitride Masks for Direct Patterning of OLED Microdisplays**
Shou-Cheng Dong, Hong Kong University of Science and Technology, Kowloon, Hong Kong

- 85.2: **2,117ppi VR LCD with Ultra-High Aperture Opening Ratio**
Tianmin Zhou, BOE Technology Group Co., Ltd., Beijing, China
- 85.3: **High-Transmittance, High-Resolution Color Filters with Tailored Structures for Microdisplays**
Byung Gwan Hyun, LG Display Co., Ltd., Seoul, South Korea
- 85.4: **Invited Paper: Plasma-Polymerized HMDSO for Thin Film Encapsulation of Micro-OLED**
Ethan Wu, AKT Display, Applied Materials Inc., Santa Clara, CA US

Session 86: Quantum Dot Perovskite (Emissive, Micro-LED, and Quantum-Dot Displays)

Friday, May 26, 2023 / 10:40 AM - 12:10 PM / Room 408B

Chair: Dr. Zhuo Chen, BOE Technology Group Co., Ltd.

Co-Chair: Seth Coe-Sullivan, NS Nanotech

- 86.1: **Control of Emission Wavelength on Perovskite Quantum Dot Based on Band Engineering**
Ryota Sato, Yamagata University, Yamagata, Japan
- 86.2: **Quantum-Confined CsPbBr₃ Perovskite Quantum Dots with Pure-Blue Emission via Ligand-Assisted Reprecipitation**
Naoaki Oshita, Yamagata University, Yamagata, Japan
- 86.3: **Why Perovskite Quantum Dots Will Be Key for LCD-, OLED- and microLED-Based Displays**
Norman Luechinger, Avantama Ltd., Stafa, Switzerland
- 86.4: **High-Performance Perovskite Nanocrystals and Photoresists for In-Pixel Color Conversion**
Bernard Wenger, Helio Display Materials, Headington, United Kingdom
- 86.5: **Late-News Paper: Green- and Red-Emitting Perovskite Nanocrystal Inks for Color Conversion Display Technologies**
Yoshihiro Ohashi, Canon Inc., Tokyo, Japan

Session 87: Sunlight Readable LCDs (Liquid Crystal Technology)

Friday, May 26, 2023 / 10:40 AM - 12:20 PM / Room 403A

Chair: Shin Tson Wu, University Of Central Florida

Co-Chair: Takahiro Ishinabe, Tohoku University

- 87.1: **Invited Paper: A Novel Reflective 90-in. TFT LCD with UV2A Technology**
Hiroyuki Hakoi, Sharp Display Technology Corporation, Nara, Japan
- 87.2: **New Reflective Liquid-Crystal Display with an Advanced Polarizer Film**
Jiaxing Wang, Beijing BOE Optoelectronics Technology Co. LTD., Beijing, China
- 87.3: **Invited Paper: High-Ambient-Contrast LCDs with Advanced Reflectionless Technology**
Jenn Jia Su, AUO Corporation, Hsinchu, Taiwan Roc
- 87.4: **Invited Paper: Specular-Free Surface for Excellent Image Quality in a Bright Environment**
Young Wook Kim, LG Display, Paju, South Korea
- 87.5: **AM MiniLED Based on LTPS-TFT Backplane with over 5,000 Dimming Zones and High Driving Bits**
Yong Yang, Wuhan China Star Optoelectronics Technology Co., Ltd., Wuhan, China

Poster Session

Thursday, May 25, 2023 / 5:00 PM - 8:00 PM / Hall G

Active-Matrix Devices

- P.1: **Study on the Mechanism of Fluorination-Enhanced Thermal Stability of IGZO Thin-Film Transistors Based on a Kinetic Model of Donor Defects**
Yuqi Wang, The Hong Kong University of Science and Technology, Kowloon, Hong Kong
- P.2: **Narrow-Bezel Gate Driver Generating Positive Pulse for AMOLED Display Using LTPO-TFT Technology**
Jin Jang, Kyunghee University, Seoul, South Korea
- P.3: **Conductive Indium-Tin-Zinc Oxide Formed Using an Oxygen Plasma Treatment Through a Silicon-Oxide Cover Layer**
Man Wong, The Hong Kong University of Science and Technology, Kowloon, Hong Kong
- P.4: **PAM and PWM Combined Oxide-TFT MiniLED Pixel Circuit Working at Low Voltage**
Zhibo Shao, Peking University, Shenzhen, China
- P.5: **Improved Split C-V Technique for Effective Mobility Extraction in Self-Aligned Top-Gate Amorphous InGaZnO TFTs with Short Channel**
Yuqing Zhang, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- P.6: **Study of Source-Gated Transistor (SGT) for Output Current Enhancement Through TCAD Simulation**
Pongsakorn Sihapitak, Nara Institute of Science and Technology, Ikoma, Japan
- P.7: **Enhanced Visible Light Response of Amorphous InZnO Thin-Film Transistors by Hydrogen Doping via Al₂O₃/SiO₂ Gate Dielectric**
Meng Zhang, Shenzhen University, Shenzhen, China
- P.8: **Synthesis of Superior-Performance InGaZnO Based on Ideal Reaction of Plasma-Enhanced Atomic Layer Deposition**
Jin-Seong Park, Hanyang University, Seoul, South Korea
- P.9: **LTPO-TFT-Based PWM Pixel Circuit for AM MicroLED Display with Falling-Time <10 μ s**
Yunfei Liu, Peking University, Shenzhen, China
- P.10: **Novel OLED Compensation TFT Circuit for Enhanced Outside Visibility**
Jaegang Jo, LG Display Co., Seoul, South Korea
- P.11: **Novel AMOLED Pixel Circuit Using Double-Gate LTPO TFTs for Variable Refresh Rate with Low Power Consumption**
Wonjun Lee, Samsung Display, Yongin, South Korea
- P.12: **Transient Drain Current Characteristics of Poly-Silicon TFTs on Plastic Substrates**
Dong Li, BOE Technology Group Co., Ltd., Beijing, China
- P.153: **Late-News Poster: Temporal Photo-Response Analysis of Inkjet-Printed Transparent Single-Walled Carbon Nanotube Thin-Film Transistors**
Yongtaek Hong, Seoul National University, Seoul, South Korea
- P.154: **Late-News Poster: High-Performance Indium-Gallium-Oxide Thin-Film-Transistors via Plasma-Enhanced Atomic-Layer Deposition**
Jae Kyeong Jeong, Hanyang University, Seoul, South Korea
- P.155: **Late-News Poster: Low-Voltage Operation a-IGZO Oxide Gate Insulator Thin-Film Transistor Using Thermal Metal**
Eun Seong Yu, Hoseo University, Asan, South Korea

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